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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
10/659,440	09/11/2003	Hiroyuki Kosuga	330-269	4097	
23117	7590 05/24/2005		EXAMINER		
NIXON & VANDERHYE, PC 901 NORTH GLEBE ROAD, 11TH FLOOR			NGUYEN, THUKHANH T		
ARLINGTON		LOOK	ART UNIT	PAPER NUMBER	
			1722		

DATE MAILED: 05/24/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

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	-	Application No.	Applicant(s)			
		10/659,440	KOSUGA ET AL.			
	Office Action Summary	Examiner	Art Unit			
		Thu Khanh T. Nguyen	1722			
Period fo	The MAILING DATE of this communicat or Reply	ion appears on the cover sheet wit	h the correspondence address	•		
THE I - Exter after - If the - If NO - Failur Any r	ORTENED STATUTORY PERIOD FOR MAILING DATE OF THIS COMMUNICA' is is ons of time may be available under the provisions of 37 SIX (6) MONTHS from the mailing date of this communical period for reply specified above is less than thirty (30) darperiod for reply is specified above, the maximum statutor re to reply within the set or extended period for reply will, if eply received by the Office later than three months after the patent term adjustment. See 37 CFR 1.704(b).	TION. 'CFR 1.136(a). In no event, however, may a reation. ys, a reply within the statutory minimum of thirty y period will apply and will expire SIX (6) MONT by statute, cause the application to become AB/	oply be timely filed (30) days will be considered timely. ICHS from the mailing date of this communicat ANDONED (35 U.S.C. § 133).	tion.		
Status						
1) 🛛	Responsive to communication(s) filed or	n 22 December 2004.				
/==	_	This action is non-final.				
·	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Dispositi	on of Claims					
5)□ 6)⊠ 7)□	Claim(s) <u>1-3 and 12-17</u> is/are pending ir 4a) Of the above claim(s) is/are we claim(s) is/are allowed. Claim(s) <u>1-3 and 12-17</u> is/are rejected. Claim(s) is/are objected to. Claim(s) are subject to restriction	vithdrawn from consideration.				
Applicati	on Papers					
10)□	The specification is objected to by the Ex The drawing(s) filed on is/are: a)[Applicant may not request that any objection Replacement drawing sheet(s) including the The oath or declaration is objected to by	☐ accepted or b)☐ objected to be to the drawing(s) be held in abeyand correction is required if the drawing(s)	ce. See 37 CFR 1.85(a). s) is objected to. See,37 CFR 1.121	. ,		
Priority u	nder 35 U.S.C. § 119					
a)[Acknowledgment is made of a claim for to All b) Some * c) None of: 1. Certified copies of the priority doc 2. Certified copies of the priority doc 3. Copies of the certified copies of the application from the International see the attached detailed Office action fo	numents have been received. Suments have been received in Apple priority documents have been a Bureau (PCT Rule 17.2(a)).	oplication No. <u>09/064,148</u> . received in this National Stage			
Attachment	• •					
2) 🔲 Notice 3) 🔯 Inform	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-9 nation Disclosure Statement(s) (PTO-1449 or PTO No(s)/Mail Date —.	948) Paper No(s)	ummary (PTO-413) //Mail Date formal Patent Application (PTO-152) 			

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DETAILED ACTION

Claim Objections

1. Claim 12 is objected to because of the following informalities: one line 1, shouldn't the "molding bare" be the molding base? Appropriate correction is required.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 3. Claims 1, 3 and 12, 14-15 and 17 are rejected under 35 U.S.C. 102(b) as being anticipated by Sugihara et al (5,296,178).

Sugihara et al teach a method for making a mold, which comprising a transfer molding surface of a predetermined shape having an alignment mark-transfer portions (Fig. 3a, 4a) on the molding surface, a base member (10) and a release film (20) formed on the surface of the base member, wherein the mold is made of metal (col. 5, lines 3-6).

In regard to claim 3, the mold (10) is having a layer of silicon carbide (col. 6, lines 57-65).

In regard to claims 12, 14-15, and 17, the mold base is formed by etching (col. 5, lines 9-12) with a finely rugged pattern on the molding surface (col. 5, lines 12-15).

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Claim Rejections - 35 USC § 103

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4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. Claims 2-3, 13 and 16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sugihara et al (5,296,178) as applied to claims 1, 3, 12, 14-15 and 17 above and further in view of Taniguchi (5,855,641).

Sugihara et al fail to disclose that the mold base comprising a hard material containing WC, SiC or amorphous carbon.

Taniguchi discloses a mold for molding optical element, comprising a mold base (1) made of material selected from a group consisting of WC, SiC, TiN, or TiC (col. 3, lines 1-4) and a layer of amorphous carbon (col. 3, lines 19-26).

It would have been obvious to one of ordinary skill in the art at the time the applicant's invention was made to modify Sato by providing the mold base made of WC, SiC, TiN, or TiC and a layer of amorphous carbon as taught by Taniguchi, because the WC, SiC, TiN, or TiC material would improve the hardness of the mold, while the amorphous carbon material would improve the adhesion of the mold and the release layer, thus, it would improve the durability of the mold.

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6. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thu Khanh T. Nguyen whose telephone number is 571-272-1136.

The examiner can normally be reached on Monday- Friday, 6:30-4:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Benjamin L. Utech can be reached on 571-272-1137. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

TN

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